

Supporting Information for:

Engineering In-Co₃O₄/H-SSZ-39(OA) Catalyst for CH₄-SCR of NO_x: Mild Oxalic Acid (OA) Leaching and Co₃O₄

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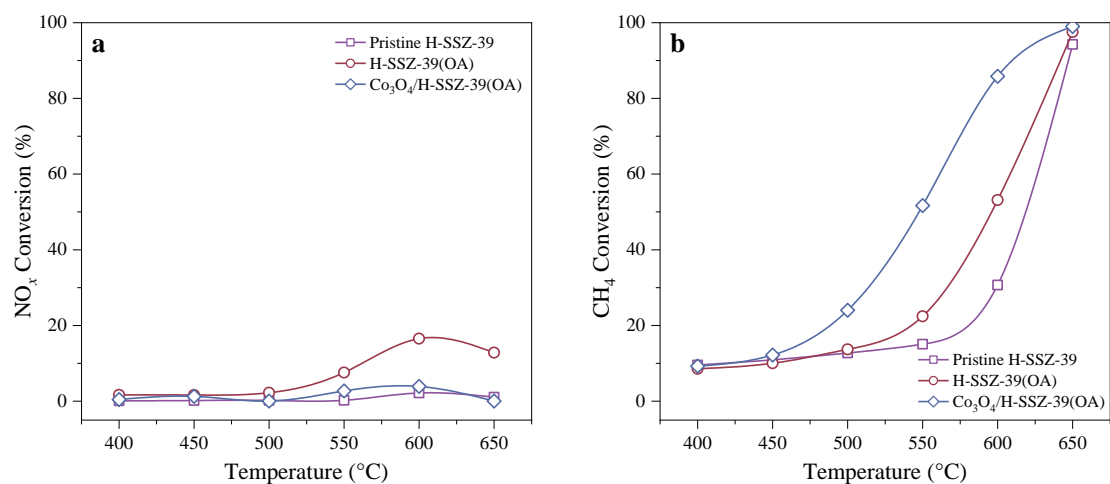


Figure S1. The CH₄-SCR deNO_x performance of Pristine H-SSZ-39, H-SSZ-39(OA), and H-Co₃O₄-SSZ-39(OA) under dry conditions. Co₃O₄/H-SSZ-39(OA) with Co₃O₄:H-SSZ-39(OA) mass ratio of 1:30 was prepared in the same way as In-Co₃O₄/H-SSZ-39(OA) except that the indium nitrate aqueous solution was replaced with an equal volume of ultrapure water. Reaction conditions: [NO] = 400 ppm, [CH₄] = 600 ppm, [O₂] = 10 vol%, Ar balance, GHSV = 24,000 h⁻¹.

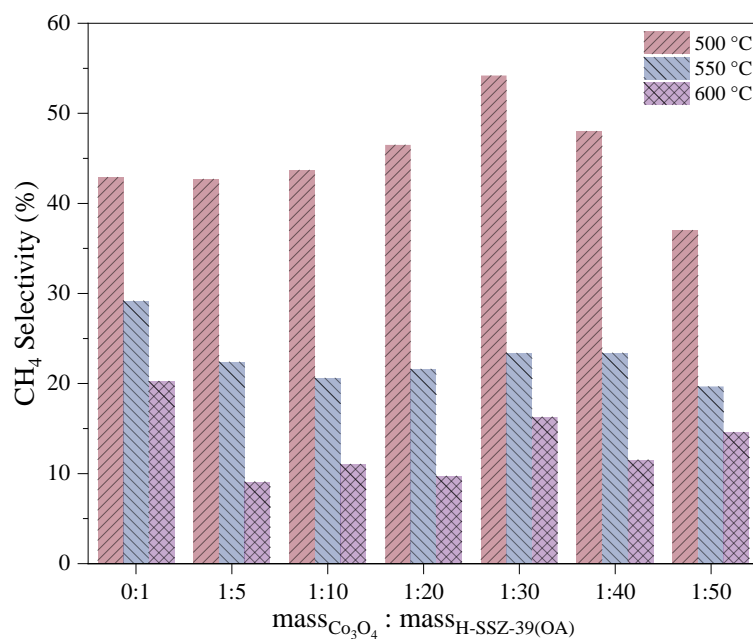


Figure S2. Effect of Co_3O_4 to H-SSZ-39(OA) mass ratio on CH_4 selectivity of the resulting catalysts under wet conditions. Reaction conditions: $[\text{NO}] = 400$ ppm, $[\text{CH}_4] = 600$ ppm, $[\text{O}_2] = 10$ vol%, $[\text{H}_2\text{O}] = 5$ vol%, Ar balance, GHSV = $24,000 \text{ h}^{-1}$.

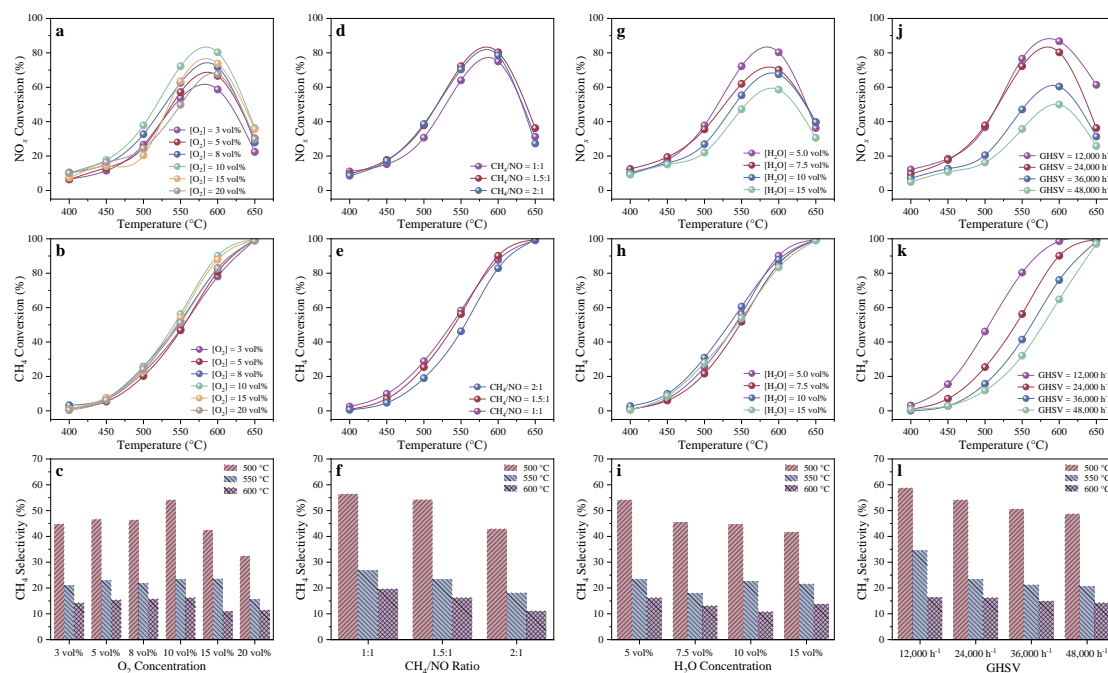


Figure S3. The CH₄-SCR deNO_x performance of In-Co₃O₄/H-SSZ-39(OA) at different (a–c) O₂ concentrations, (d–f) CH₄/NO ratios, (g–i) water vapor concentrations, and (j–l) GHSVs. Reaction conditions in (a–c): [NO] = 400 ppm, [O₂] = 3–20 vol%, [CH₄] = 600 ppm, [H₂O] = 5 vol%, Ar balance, GHSV = 24,000 h⁻¹. Reaction conditions in (d–f): [NO] = 400 ppm, [O₂] = 10 vol%, [CH₄] = 400–800 ppm, [H₂O] = 5 vol%, Ar balance, GHSV = 24,000 h⁻¹. Reaction conditions in (g–i): [NO] = 400 ppm, [O₂] = 10 vol%, [CH₄] = 600 ppm, [H₂O] = 5–15 vol%, Ar balance, GHSV = 24,000 h⁻¹. Reaction conditions in (j–l): [NO] = 400 ppm, [O₂] = 10 vol%, [CH₄] = 600 ppm, [H₂O] = 5 vol%, Ar balance, GHSV = 12,000–48,000 h⁻¹.

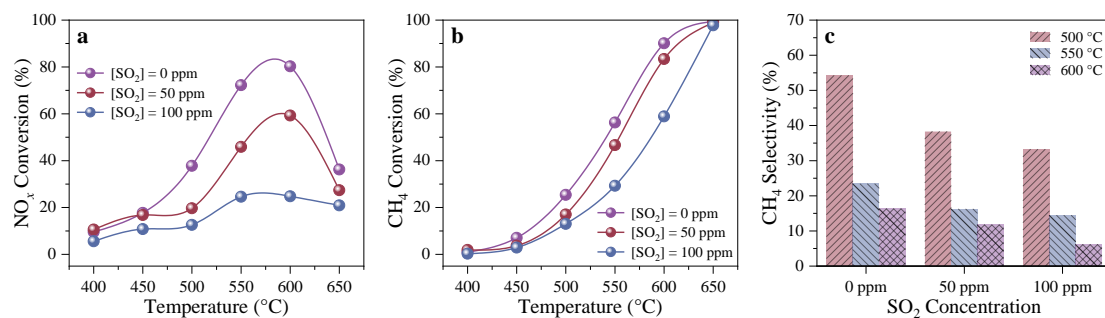


Figure S4. The CH₄-SCR deNO_x performance of In-Co₃O₄/H-SSZ-39(OA) at different SO₂ concentrations and in the presence of 5 vol% H₂O. Reaction conditions: [NO] = 400 ppm, [CH₄] = 600 ppm, [O₂] = 10 vol%, [H₂O] = 5 vol%, [SO₂] = 0–100 ppm, Ar balance, GHSV = 24,000 h⁻¹.

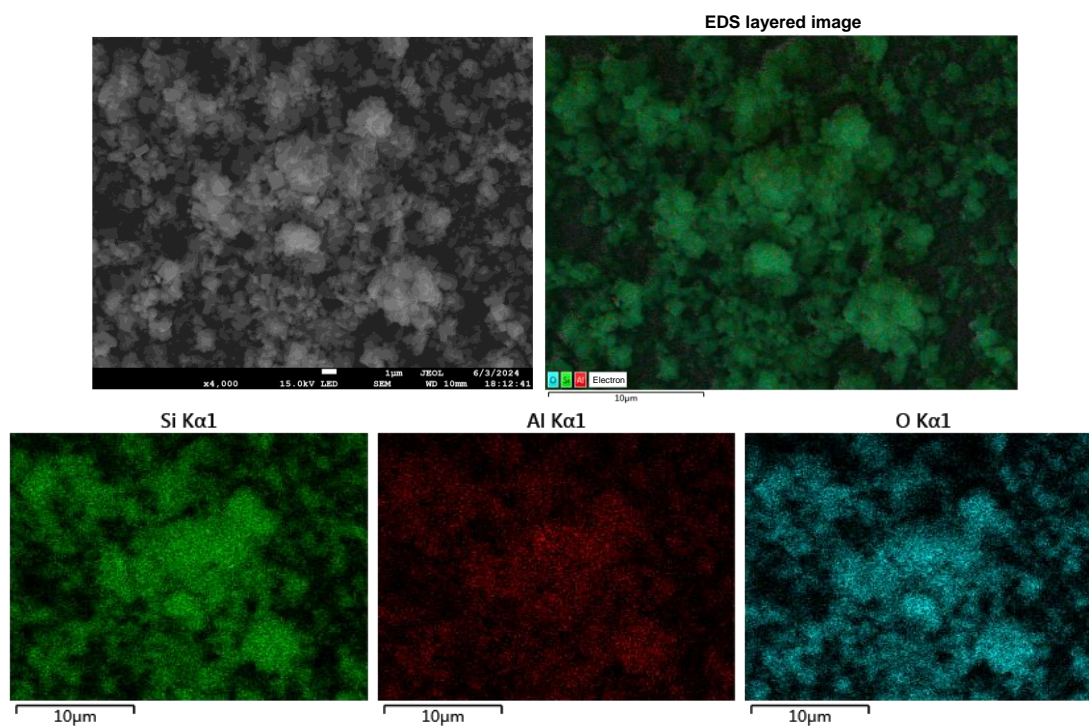


Figure S5. SEM-EDS mapping of Pristine H-SSZ-39.

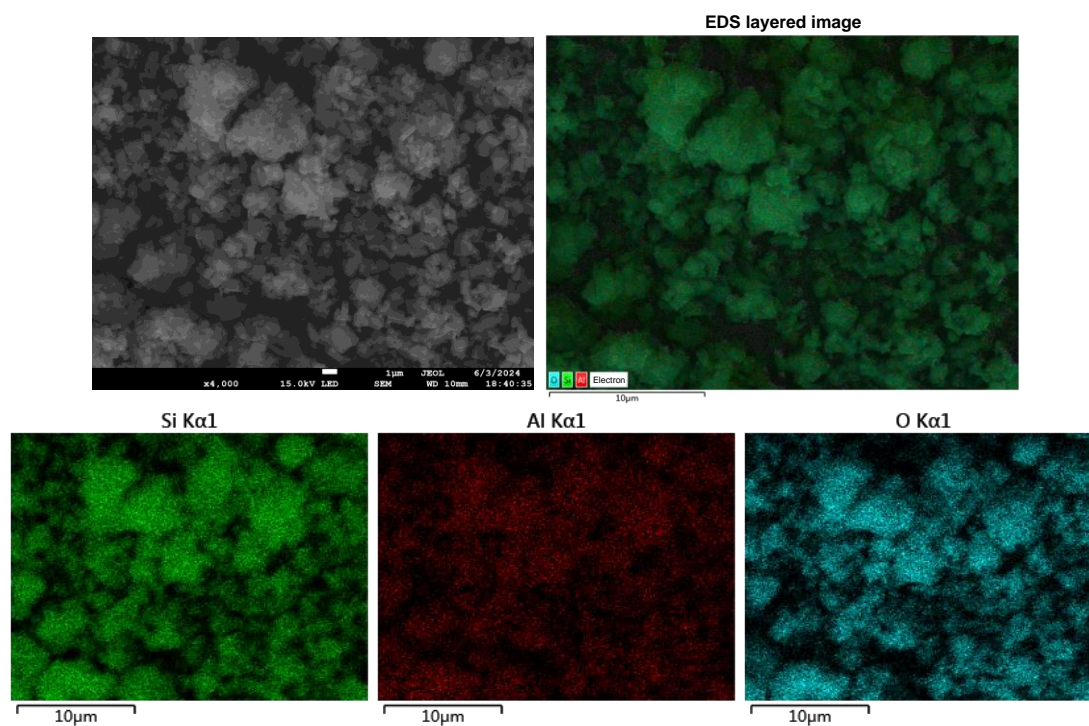


Figure S6. SEM-EDS mapping of H-SSZ-39(OA).

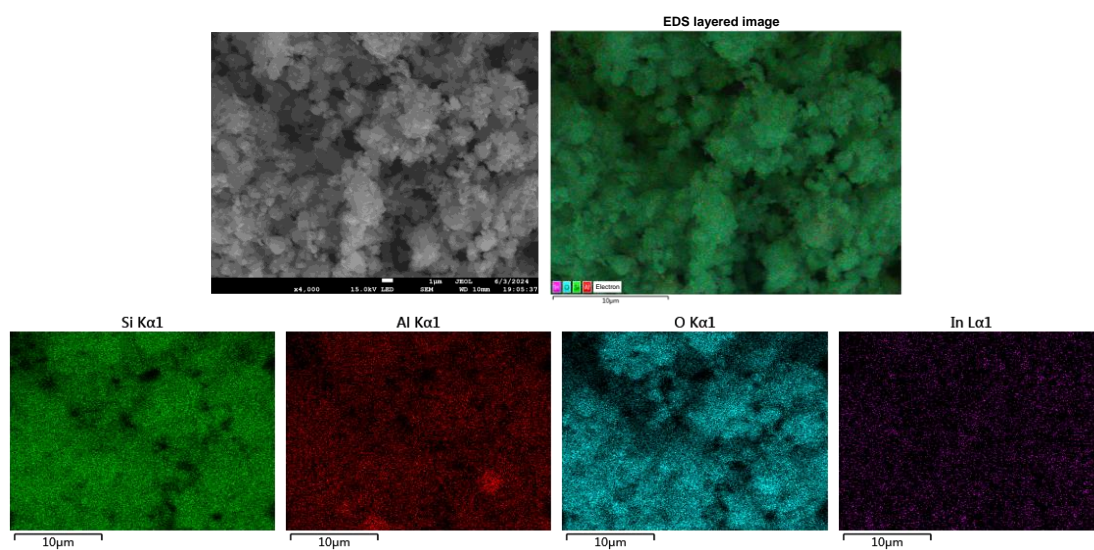


Figure S7. SEM-EDS mapping of In/H-SSZ-39(OA).

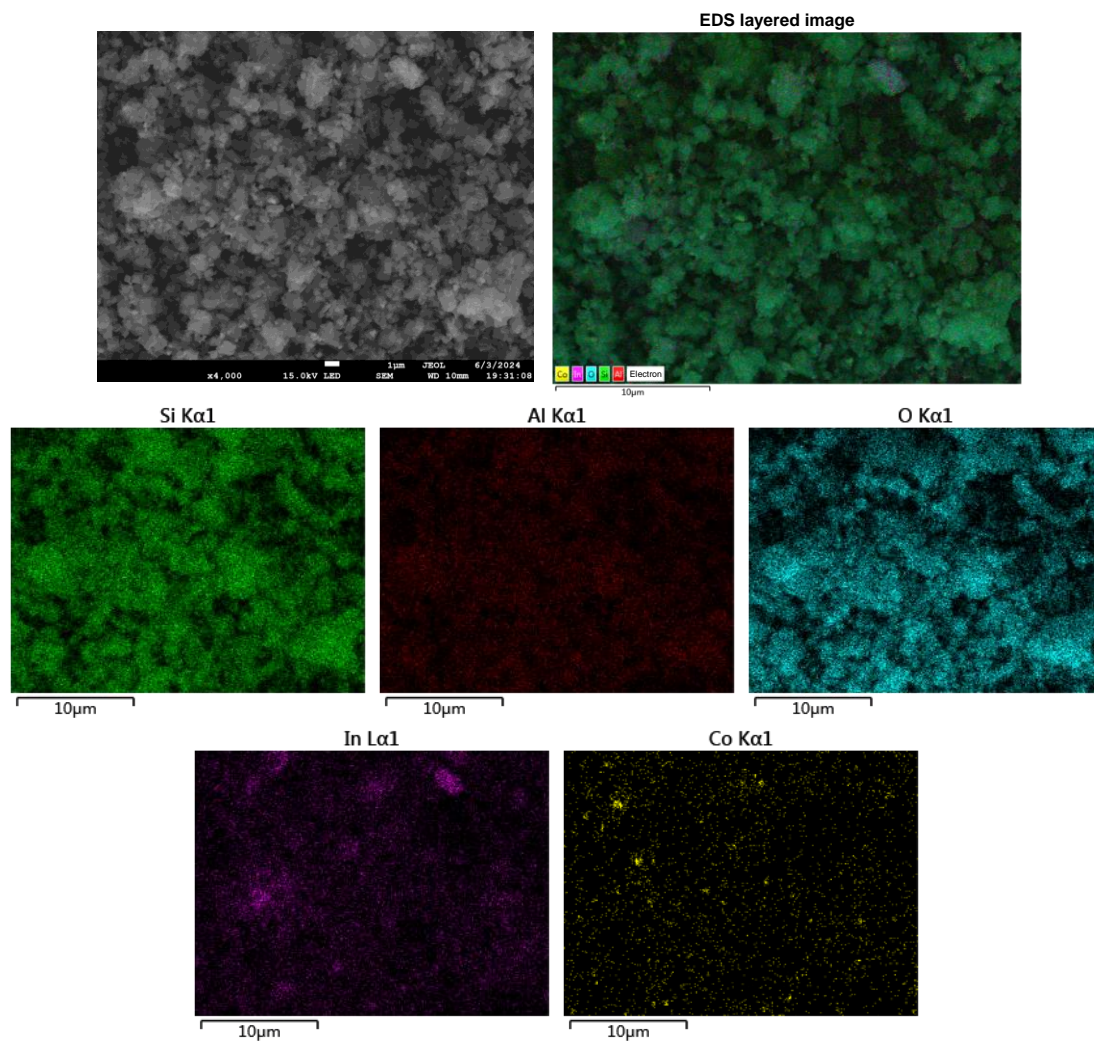


Figure S8. SEM-EDS mapping of In-Co₃O₄/H-SSZ-39(OA).

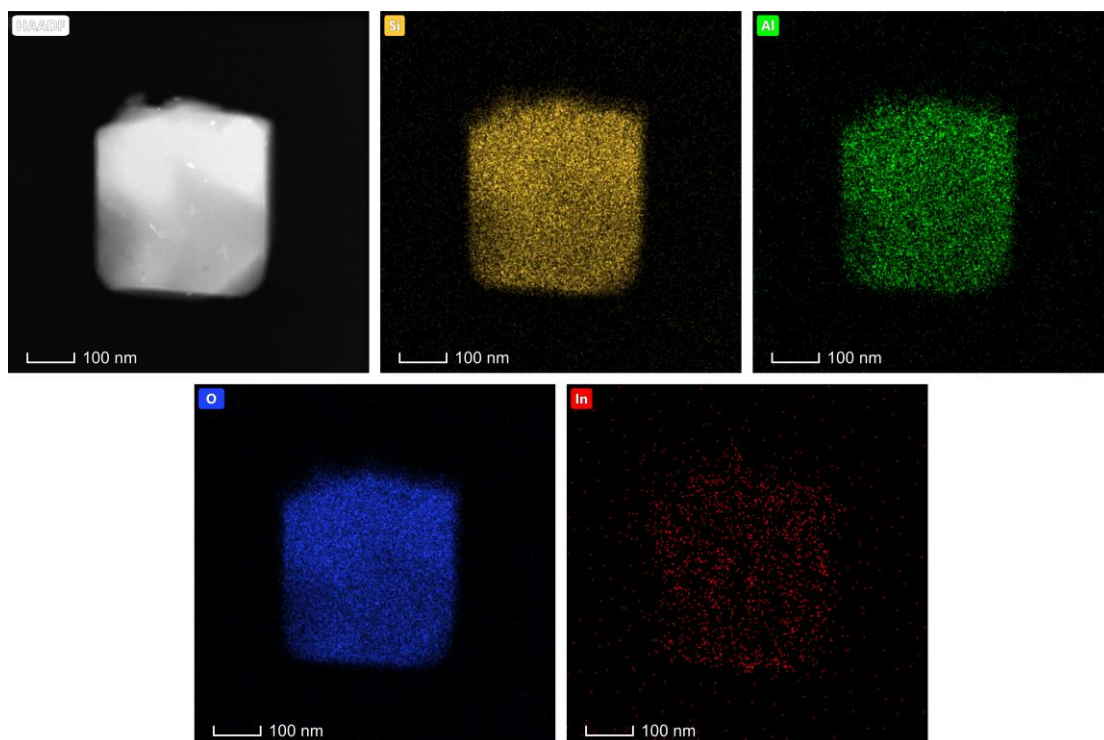


Figure S9. HAADF-STEM and elemental mapping images of In/H-SSZ-39(OA).

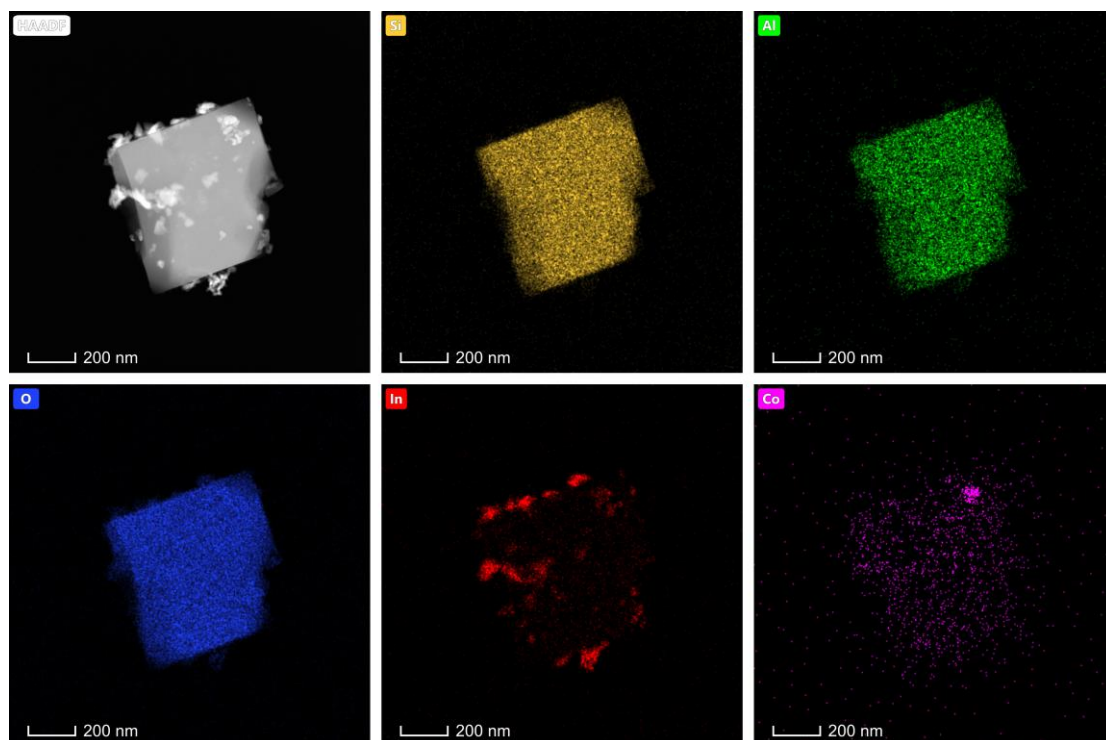


Figure S10. HAADF-STEM and elemental mapping images of In-Co₃O₄/H-SSZ-39(OA).

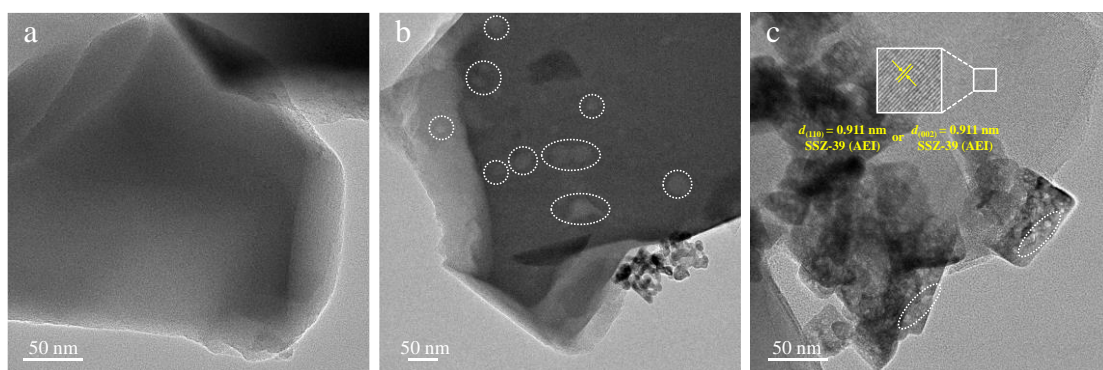


Figure S11. HRTEM images of (a) Pristine H-SSZ-39, (b) In/H-SSZ-39(OA), and (c) In-Co₃O₄/H-SSZ-39(OA).

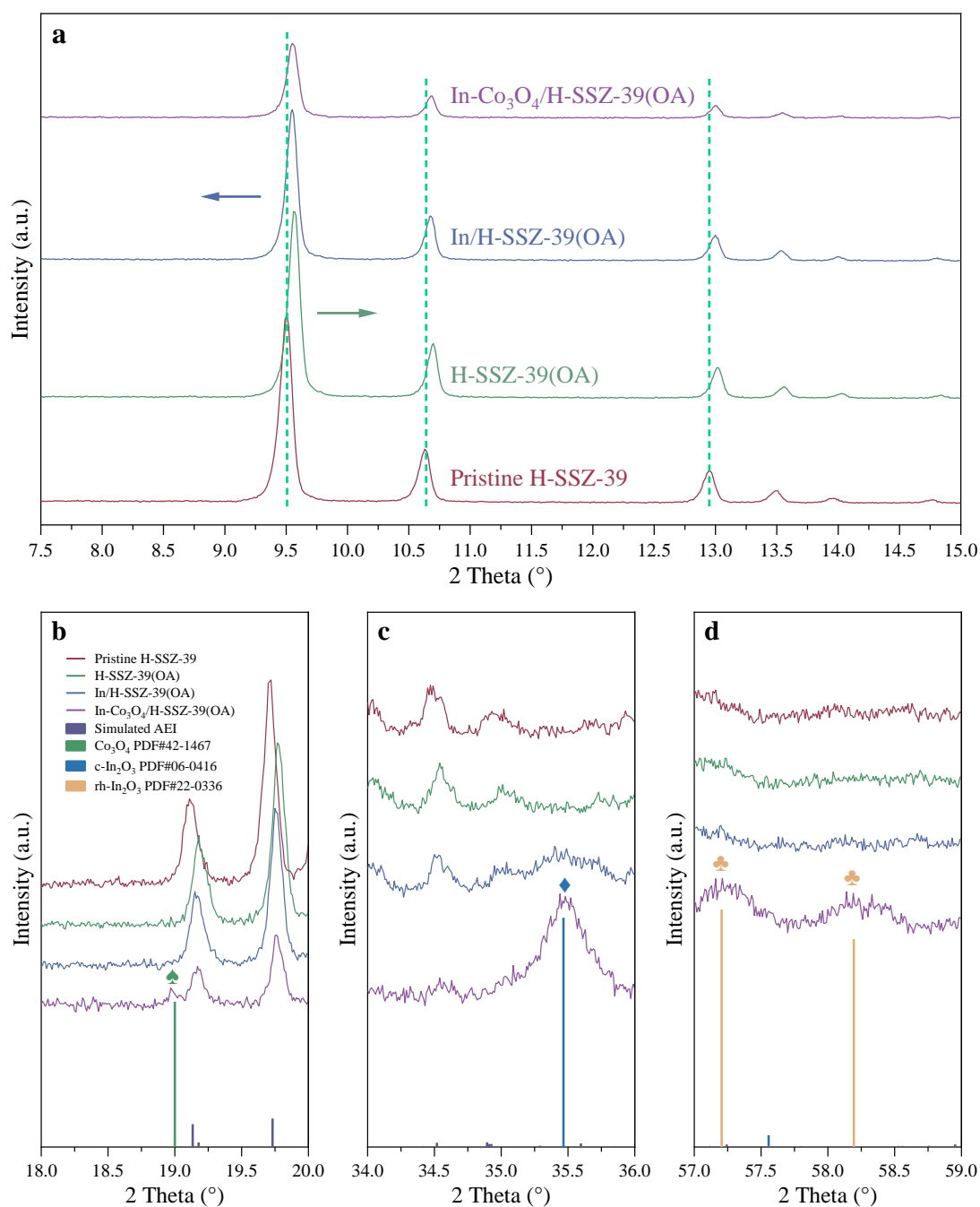


Figure S12. Locally enlarged PXRD patterns in the range of (a) 7.5–15.0°, (b) 18.0–20.0°, (c) 34.0–36.0°, and (d) 57.0–59.0° of Pristine H-SSZ-39, H-SSZ-39(OA), In/H-SSZ-39(OA), and In/H-Co₃O₄-SSZ-39(OA).

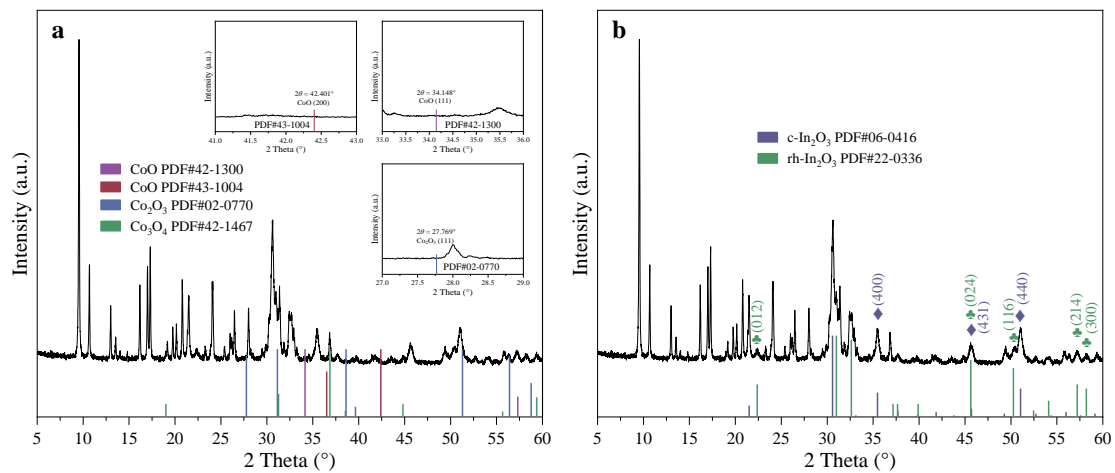


Figure S13. PXRD pattern of In-Co₃O₄/H-SSZ-39(OA) in comparison with standard PXRD patterns of (a) cobalt oxides and (b) indium oxides.

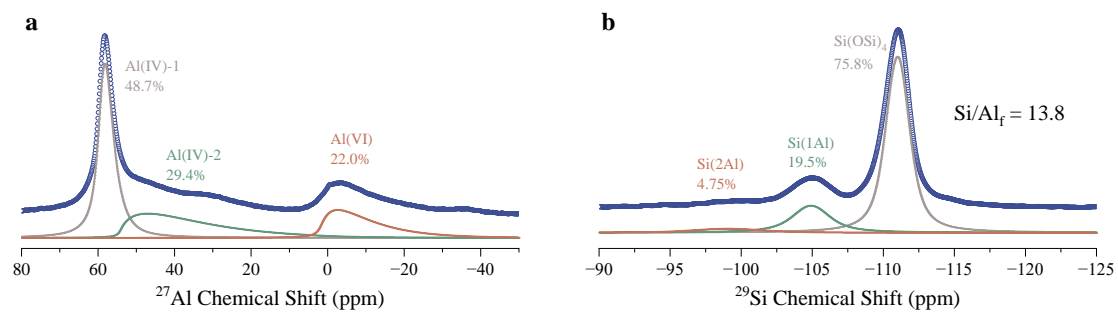


Figure S14. (a) ^{27}Al MAS SSNMR and (b) ^{29}Si MAS SSNMR spectra of H-SSZ-39(OA).

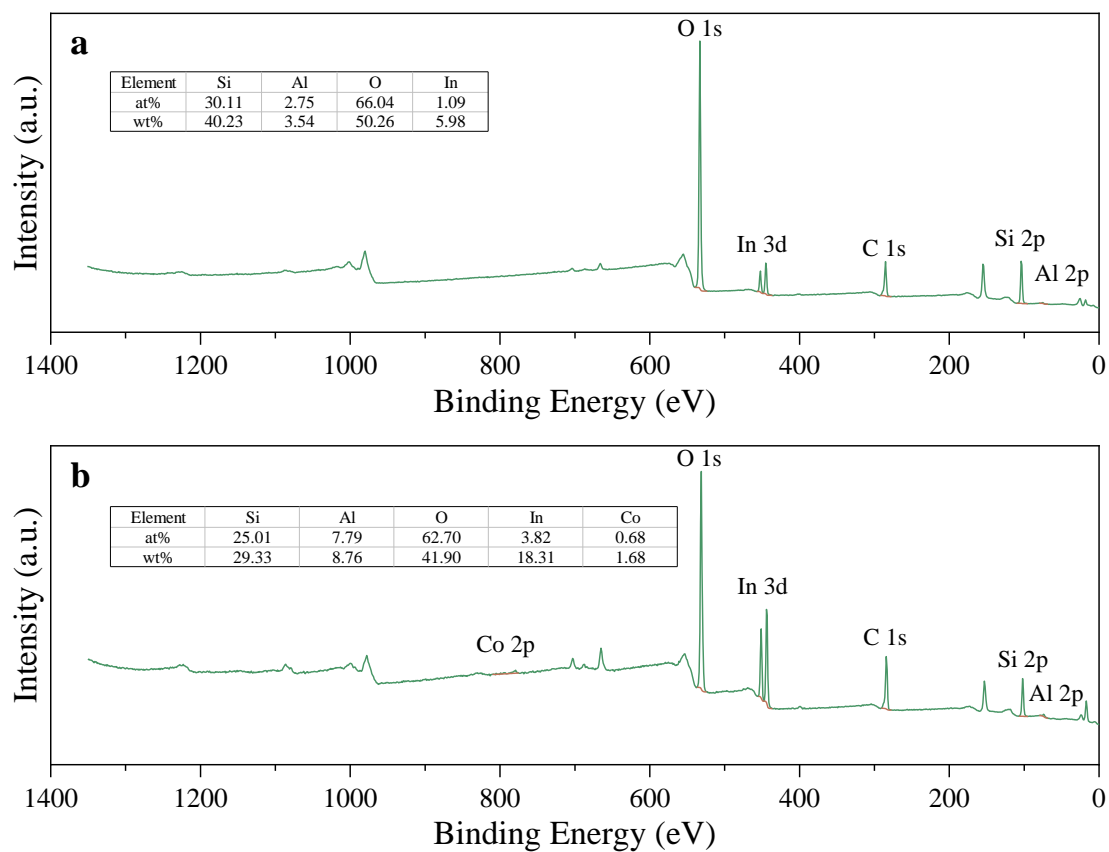


Figure S15. XPS survey spectra and corresponding surface element contents of **(a)** In/H-SSZ-39(OA) and **(b)** In-Co₃O₄/H-SSZ-39(OA).